Recombination in Semiconductors: Appearance of Non-equilibrium Carriers due to Injection or Redistribution in the Sample

I. N. Volovichev, G. Espejo, and Yu. G. Gurevich Departmento de F sica, CINVESTAV | I.P.N., Apdo. Postal 14 (740, Mexico, D. F. 07000, Mexico

O. Yu. Titov^x
CICATA | I.P.N., Jose Siurob No. 10,
Col. Alameda, C.P. 76040,
Santiago de Queretaro, Qro., Mexico

A. Meriuts

K harkov Polytechnic University, 21 Frunze Str., K harkov 310002, Ukraine (D ated: M arch 22, 2024)

It is shown that the traditional approach for consideration of recombination under condition of steady-state current in the absence of external carrier generation is internally contradictory. Sometimes the approach leads to obviously incorrect results. Such situations are demonstrated and a new method for consideration of recombination is proposed.

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In the present paper we would like to consider some internal inconsistencies in the conventional description when we have carrier recomb ination under condition of steady-state current. Practically all text-books 1,2,3,4,5 present technique to solve the given problem based on the solution of a set of continuity equations:

$$divj_n = eR_n;$$
 $divj_0 = eR_p$

$$R_n = \frac{n}{n}; \qquad R_p = \frac{p}{p}; \tag{1}$$

where $_{\rm n}$, $_{\rm p}$ are life times of electrons and holes respectively.

O bviously, by virtue of charge preservation law an extra condition

$$R_n = R_p \tag{2}$$

should hold. Although it is not mentioned in the literature that Eq. (2) makes the system overdeterm ined. Some authors³ use the latter expression as an equation to indicate the carrier concentration or to reduce by one the number of unknowns in the problem. However, such approach seems to be incorrect because the Eq. (2) is not a new condition for the concentration of non-equilibrium carriers, rather it is the criterion for correctness of the recombination description, and should full lidentically at any concentration of non-equilibrium carriers. Probably due to this reason other approach frequently is used, 1,2,3,4,5,6,7 assuming

$$R_n R_p = \frac{p}{p}; (3)$$

where pmeans the non-equilibrium concentration of minority carriers. Just this approach is classical and is used widely both in text-books, and in papers devoted to kinetic phenomena in semiconductors.

This description possesses a serious inconsistency. It becomes especially obvious if we consider in jection of majority carriers. From physical reasons it is evident: in jected non-equilibrium majority carriers should recombine. While from a form alpoint of view, as far as non-equilibrium minority carriers do not occur (p = 0) the recombination rates are

also equal to zero $R_n = R_p = 0$. Below we consider m ore cases, when the conventional description of a recombination is unacceptable.

E lim ination of the given inconsistency is not complicated and can be based on the well known form ulas presented in the above mentioned text-books. It is easy to get the following expressions for recombination processes by a sequential statistical consideration of transitions between valence and conduction bands and between the bands and impurity levels (if they are present):

$$R_n = R_p = (np \quad n_i^2) \tag{4}$$

for interband recombination and

$$R_{n} = R_{p} = \frac{np \quad r_{1}^{2}}{\frac{0}{n} (p + p_{1}) + \frac{0}{p} (n + n_{1})}$$
 (5)

for recom bination through an impurity level according to the Shockley-Read model.8

Here is the recombination factor, n_i is the carrier concentration of the intrinsic sem iconductor, $n_{i,p}$, n_{1} , and p_{1} are characteristics of the impurity level.

We should emphasize once again that the equality $R_n = R_p$ is inherent in correct model and holds identically, not causing overdeterm ination of the system.

Linearizing these expressions for the case of weak deviation from the condition of them odynamic equilibrium (the changes of carrier concentrations due to current are small on comparison with their equilibrium values), we have for both cases:

$$R_n = R_p = \frac{n}{n} + \frac{p}{p}; \quad w \text{ ith } \frac{n}{p} = \frac{n_0}{p_0};$$
 (6)

Just these expressions, being used in Eqs. (1), elim inate all mentioned above inconsistencies.

Also let us pay attention to another aspects of the problem. As it is easy to notice from Eqs. (6), in bipolar sem iconductors generally it is impossible to introduce correctly a life time of carriers concept. An exception is the case of quasineutrality 9 when n=p and the introduction of united life time of carriers 1 $_n^1 + _p^1$ becomes possible. In the absence of quasineutrality it is plausible to speak about life time of carriers and to use the conventional approach Eq. (3) only if (n=p) $(n=p) = (n_0=p_0)$ (here, as it was mentioned above, not means concentration of majority carriers). Naturally, the full ment of this condition is not a priori obvious.

Let us notice that another baseless idea is widespread, namely presence of only interband recombination is su cient condition for the equality n = p to be fullled. But there is no proof for this conclusion, and moreover, a case of injection obviously contradicts it.

Thus, in general case for static current either it is impossible to introduce correctly the concept of life time or life times are the same for both electrons and holes.

For the sake of justice we should notice, that as a rule in the literature either injection phenomena (when linearized equations are not valid due to high concentration of non-equilibrium carriers) or just the quasineutrality approach are considered. From our point of view, it is just the only explanation why so internally contradictory method to describe kinetic phenomena with the presence of recombination is widely used in many text-books and monographies.

Similar problem arises for description of a surface recombination. Correct expression for it should be obtained from consideration of transitions between the bands and impurity levels both inside the sem iconductor, and between bands of dierent sem iconductors (or between bands of the sem iconductor and metal in case of a metal-sem iconductor contact). The correct expression for the surface recombination rate should ensure identical equality of electron and hole recombination rates at any concentration of non-equilibrium carriers at the contact (as in case of volume recombination). It is obvious that in general case the expression of the following form meets the requirement:

$$S = S_n n + S_p p; (7)$$

where coe cients s n,p should be obtained from microscopic consideration of corresponding transitions.

Some authors use that formula at initial stage of calculations, then giving it up and proceeding to the traditional (but incorrect!) expression $S_n = s_n$ n, $S_p = s_p$ p. Rather characteristic consideration is presented in Ref. 6, where quasilevels of electrons and holes are assumed to coincide. That, in its turn, in plicitly presumes in nite surface (or volume) recombination rate.

The situation becomes more complicated, if there is an inhomogeneous temperature distribution (temperature eld) in the semiconductor. It is problematic to choose a concentration which can be considered as a level of reference of non-equilibrium concentration (for example, which one should be taken as the reference: $n_0(T_0)$, $n_0[T(x)]$, $n_0[T(x)]$, etc). A way out from this position can be found by successive consideration of process of establishment of \equilibrium"

(or in constancy of electrochem ical potential in the sam ple) in the circuit. 10 E vidently, this method is acceptable only if the tem perature eld is given. O ther, universal and more simple, from our point of view, way to solve this problem is to return to statistical consideration of transitions of carriers between bands and impurity levels in the presence of tem perature eld. In this case the value of concentration in thermodynamic equilibrium (in the absence of the tem perature gradient) or the values corresponding to the mean temperature of the sample can be accepted as the reference level of concentration (i.e. n_0 and p_0). This method works as well in the case, when the temperature eld should be determined self-consistently.

Thus for interband recombination we come back to expressions (4), where the values and n_i are functions of temperature (= [T (x)], $n_i = n_i[T (x)]$). For small deviation from the equilibrium state (after linearization) we receive the following expressions for volume recombination rate in the temperature eld:

$$R_n = R_p = \frac{n}{n} + \frac{p}{p} + T;$$
 (8)

where (1=2)($0n_i=0T$); T T T; T₀ is the equilibrium temperature (above-mentioned reference level of temperature). Let us note that in the approximation of small nonequilibrium carrier concentrations (n n₀, p p₀) thermal dependence of the recombination factor does not manifest itself.

Thus, the presence of a tem perature gradient results in appearance of an additional term in expressions for recombination rates. This term takes into account the change of the rate of therm algeneration (which, as it is well known, is proportional to squared concentration of intrinsic sem iconductor at given temperature). As far as we know, anywhere but Ref. 10, this contribution has not been taken into account in consideration of therm oelectric phenomena.

Finally, if there is no uni ed tem perature of carriers and phonons (for example, hot electrons situation³), it is easy to prove by a similar way that one more term appears in the expressions for recombination rates. It proportional to the heating of carriers: 11

$$R_n = R_p = \frac{n}{n} + \frac{p}{p} + (T(x) - T_0) + (T_e - T_0);$$
 (9)

where T_e is the temperature of hot electrons, T(x) is assumed to be the lattice temperature. The coecient depends on concentration of carriers, the lattice temperature and capture factor of carriers by the impurity level (or corresponding value for interband recombination).

Let us note that a coordinate dependence of electron tem perature $T_e = T_e(x)$, that is a general case, does not a ect the term (T(x)) T_0 from Eq. (9), which is the same as in Eq. (8). This is due to the fact that this term describes therm algeneration of carriers, which can not be in uenced by population of the conduction band (i.e. by electron tem perature) just because of huge concentration of free states in the conduction band.

Thus, we would like to pay attention of researchers to the fact, that holding a mm place approach to the description of a recombination in steady-state mode is internally contradictory and in many cases, especially common to modem problems, its hasty application can lead to incorrect results. We would like to mention, as an example, thin-lm devices, where it is easy to disturb the quasineutrality and to generate essential gradients of temperature and energy nonequilibrium of carriers due to carriers heating by an applied eld.

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Perm anent address: Institute for Radiophysics and Electronics, National Academy of Sciences of Ukraine, Kharkov 310085, Kharkov 310085, Ukraine.

 $^{^{\}mathrm{y}}$ E lectronic address: gespejo@ s.c.investav.m x

 $^{^{}z}$ E lectronic address: gurevich@ s.c.investav.m x

^{*} Electronic address: oleg.titov@aleph-tec.com

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